

Updated 12/19/2022

**Symp 1 – Characterization of Structure–Property Relationships in Functional Ceramics**

**Nasim Alem**, Penn State University

**David Flannigan**, University of Minnesota

**Xi Jiang**, Lawrence Berkeley National Laboratory

**Jian Luo**, University of California, San Diego

**Hugh Simons**, Technical University of Denmark, Denmark

**Rama Vasudevan**, Oak Ridge National Laboratory

**Symp 2 – Advanced Electronic Materials: Processing Structures, Properties, and Applications**

**Jessica Andrews**, Sheffield University, UK

**Michelle Dolgos**, University of Calgary, Canada

**Jacob Jones**, North Carolina State University

**Zdravko Kutnjak**, Jozef Stefan Institute, Slovenia

**Xiaoli Tan**, Iowa State University

**Chun-Ming Wang**, Shandong University, China

**Xinhua Zhu**, Nanjing University, China

**Symp 3 – Frontiers in Ferroic Oxides: Synthesis, Structure, Properties, and Applications**

**Jieun Kim**, University of Wisconsin

**Jian Liu**, University of Tennessee

**Daniel Sando**, University of Canterbury/University of New South Wales, New Zealand

**Mads Weber**, Université Le Mans, France

**Symp 4 – Complex Oxide Thin Films and Heterostructures: From Synthesis to Strain/Interface-engineered Emergent Properties**

**Charles Ahn**, Yale University

**Matt Barone**, Cornell University

**Dillon Fong**, Argonne National Laboratory

**Marta Gilbert**, TU Wien, Austria

**Felix Gunkel**, Forschungszentrum Jülich, Germany

**Bharat Jalan**, University of Minnesota

**Ho Nyung Lee**, Oak Ridge National Laboratory

**Mingzhao Liu**, Brookhaven National Laboratory

**Lane Martin**, University of California, Berkeley

**Hanjong Paik**, University of Oklahoma

**Susan Trolier-McKinstry**, Penn State University

**Hongguang Wang**, Max Planck Institute for Solid State Research, Germany

**Hui (Claire) Xiong**, Boise State University

**Symp 5 – Mesoscale Phenomena in Ferroic Nanostructures: From Patterns to Functionalities**

**Yehonadav Bekenstein**, Technion - Israel Institute of Technology, Israel

**Andrei Kholkin**, Aveiro Institute of Materials, Portugal

**Lane Martin**, University of Berkeley

**Andrew M. Rappe**, University of Pennsylvania

**Nives Strkal**, University of Cambridge, UK

**Susan Trolier-McKinstry**, Penn State University

## **Symp 6 – Emerging Semiconductor Materials and Interfaces**

**Fikadu Alema**, Agnitron Technology

**Guang Bian**, University of Missouri

**Michael Chilcote**, Oak Ridge National Laboratory

**Joseph Corbett**, Miami University

**Sumner Harris**, Oak Ridge National Laboratory

**Il Jeon**, SungKyunKwan University, Korea

**Joon Sue Lee**, University of Tennessee

**Zhenqiang (Jack) Ma**, University of Wisconsin, Madison

**Takuji Maekawa**, Rohm Co., Ltd., Japan

**Alessandro Mazza**, Los Alamos National Lab

**Jingjing Shi**, University of Florida

**David Storm**, Naval Research Laboratory

**Saien Xie**, Princeton University

## **Symp 7 – Superconducting and Related Materials: From Basic Science to Applications**

**Denis Arcon**, Institute Jozef Stefan, Slovenia

**John Bulmer**, U.S. Air Force Research Laboratory

**Timothy Haugan**, U.S. Air Force Research Laboratory

**Gaoting Lin**, Shanghai Jiao Tong University, China

**Bing Lv**, University of Texas, Dallas

**Petro Maksymovych**, Oak Ridge National Laboratory

**Michael Newburger**, U.S. Air Force Research Laboratory

**Michael Osofsky**, Naval Research Laboratory

**Srinivasa Rao Singamaneni**, University of Texas, El Paso

**Michael Sumption**, The Ohio State University

**Weida Wu**, Rutgers University

**Haidong Zhou**, University of Tennessee

### **Symp 8 – Data-driven and Model-supported Research of Structure-property Relationships in Complex Electroceramics**

**Ayana Ghosh**, Oak Ridge National Laboratory

**James Roscow**, Bath University, UK

**Hugh Simons**, Danish Technical University, Denmark

### **Symp 9 – Ion-Conducting Ceramics**

**No invited speakers**

### **Symp 10 – Defects and Transport in Ceramics**

**Roger De Souza**, RWTH Aachen, Germany

**Yuichi Ikuhara**, University of Tokyo, Japan

**Nicola Perry**, University of Illinois Urbana-Champaign

**Clive Randall**, Penn State University

**Le Wang**, Pacific Northwestern National Laboratory (PNNL)

### **Symp 11 – Evolution of Structure and Chemistry of Grain Boundaries and Their Networks as a Function of Material Processing**

**Kris Behler**, US Army Research Lab (SURVICE Engineering)

**Shen Dillon**, University of California, Irvine

**Edwin Garcia**, Purdue University

**Joshua Gild**, US Naval Research Laboratory

**Sara Mills**, US Naval Research Laboratory

**Clive Randall**, Penn State University

### **Symp 12 –Materials, Devices, and Applications in 6G Telecommunications**

**Florian Bergmann**, NIST

**Bryan Bosworth**, NIST

**Michael Lanagan**, Penn State University

**Aravind Nagulu**, Washington University in St. Louis

**Nate Orloff**, NIST

**Say Phommakesone**, Keysight Technologies, Inc.

### **Symp 13 - Agile Design of Electronic Materials: Aligned Computational and Experimental Approaches and Materials Informatics**

**Geoffroy Hautier**, Dartmouth College

**Nav Nidhi Rajput**, Stony Brook University

**Karsten Reuter**, Fritz-Haber-Institut der MPG, Germany

**Rama Vasudevan**, Oak Ridge National Laboratory

**Bilge Yildiz**, Massachusetts Institute of Technology

## **Symp 14 – Emergent Properties and Applications of Advanced Magnetic Materials**

**Dustin Gilbert**, University of Tennessee

**Chris Leighton**, University of Minnesota

**Caroline Ross**, MIT

**Pinku Roy**, University at Buffalo/Los Alamos National Laboratory

**Connor Smith**, U.S. Naval Academy

**Morgan Trassin**, ETH Zurich, Switzerland

## **Symp 15 - Advanced Microelectronics**

**Geoff Brennecka**, Colorado School of Mines

**Ying-Hao Chu**, National Tsing Hua University, Taiwan

**Lauren Garten**, Georgia Institute of Technology

**Markus Hellenbrand**, University of Cambridge, UK

**Michael Hoffmann**, UC Berkeley

**Deok-Hwang Kwon**, Korea Institute of Science and Technology, Korea

**Kai Liu**, Georgetown University

**Shriram Ramanathan**, Rutgers University

**Patrick Shamberger**, Texas A&M University

**Haiyan Wang**, Purdue University

## **Symp 16 – *In situ/operando* Characterization of Nanomaterials**

**Matthew Brahlek**, Oak Ridge National Laboratory

**Yan Chen**, Oak Ridge National Laboratory

**Lisa DeBeer-Schmitt**, Oak Ridge National Laboratory

**Madeline Dressel Dukes**, Protochips, Inc.

**Myung-Geun Han**, Brookhaven National Laboratory

**Katherine Harmon**, Argonne National Laboratory

**Leopoldo Molina-Luna**, Technische Universität Darmstadt, Germany

**Peco Myint**, Argonne National Laboratory

**Yaguo Wang**, University of Texas, Austin

**Yimei Zhu**, Brookhaven National Laboratory